

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Patent Application of

T. HIROSE et al

Serial No. 09/774,723

Group Art Unit: 2876

Filed: February 1, 2001

Examiner: D. Lee

For:

POLISHING PAD SURFACE CONDITION EVALUATION METHOD AND AN

APPARATUS THEREOF AND A METHOD OF PRODUCING A

SEMICONDUCTOR DEVICE

RESPONSE TO RESTRICTION REQUIREMENT

Commissioner for Patents Washington, D.C. 20231

December 16, 2002

Sir:

In response to the Restriction Requirement mailed

November 15, 2002, the Applicants elect Group II, claims 5-8
and 16-19, without traverse.

Examination of these claims is respectfully requested.

The Commissioner is hereby authorized to charge any payment due, or to credit any overpayment, to Deposit Account No. 50-1417, including any Extension of Time Fees that may be necessary.

Respectfully submitted,

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Date: December 16, 2002

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